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SG-II-Up prototype final optics assembly: optical damage and clean-gas control

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Abstract

The Shenguang-II Upgrade (SG-II Up) facility is an under-construction high-power laser driver with eight beams, 24 kJ energy, 3 ns pulse duration and ultraviolet laser output, in the Shanghai Institute of Optics and Fine Mechanics, China. The prototype design and experimental research of the prototype final optics assembly (FOA), which is one of the most important parts of the SG-II Up facility, have been completed on the ninth beam of the SG-II facility. Thirty-three shots were fired using 1- ω energy from 1000 to 4500 J and 3- ω energy from 500 to 2403 J with a 3 ns square pulse. During the experiments, emphasis was given to the process of optical damage and to the effects of clean-gas control. A numerical model of the FOA generated by the Integrated Computer Engineering and Manufacturing code for Computational Fluid Dynamics (ICEMCFD) demonstrated that a flux within 1–5 l s⁻¹ and a 180 s period is effectual to avoid contaminant sputtering to the optics. The presence of surface ‘mooning’ damage and surface spots located outside the clear aperture are induced by contaminants such as wire, silica gel and millimeter order fiber and metal.

Keywords: Final Optics Assembly; optical damage; SG-II-Up

1. Introduction

The Shenguang-II Upgrade (SG-II Up) is a kilojoule-class solid-state laser and targeting facility under construction by the National Laboratory on High Power Lasers and Physics. The amplified 1053 nm beams from the Nd:glass driver are transported (at 40 kJ for 3 ns) in 2 × 2 quads with eight beams with aperture size 310 mm × 310 mm to the 2.4 m-diameter target chamber where eight final optics assemblies (FOAs) convert each beam to the third harmonic, separate the residual 1053 and 527 nm beams, and finally focus the 351 nm beam onto the target.

The prototype design and manufacture of the FOA have been finished, and it is different from the NIF-FOA and the SG-II-FOA^[1–6]. The FOA consists of fixed interfaces to the target chamber and five modules that house eight full-aperture optics, as shown in Figure 1. The aperture sizes of these optics are as large as 370 mm × 370 mm. The corresponding functions of the various optics, as shown in the aforementioned figure, are as follows.

1. Phase plate – conditions the beam phases to form an ~750 μm flat-top profile.
2. Vacuum window – provides a near-vacuum FOA environment.
3. Frequency conversion crystals – convert the 1053 nm beam to a 351 nm beam.
4. Wedged plate – separates the residual 1053 and 527 nm light with 351 nm light, and the refractive low-energy 351 nm light to a power sensor on the output surface.
5. Focus lens – focuses the 351 nm beam onto the target; the focal length is 2234 mm.
6. Beam sampling grating (BSG) and main debris shield (MDS) – providing a low-efficiency grating to the input surface for energy sampling (calorimetry) and large-object protection for upstream (more expensive) optics.
7. Disposable debris shield (DDS) – thin, inexpensive optics for primary debris protection.

The frequency converter is a cascade sum-frequency generation design consisting of a 12.5 mm-thick Type-I KDP

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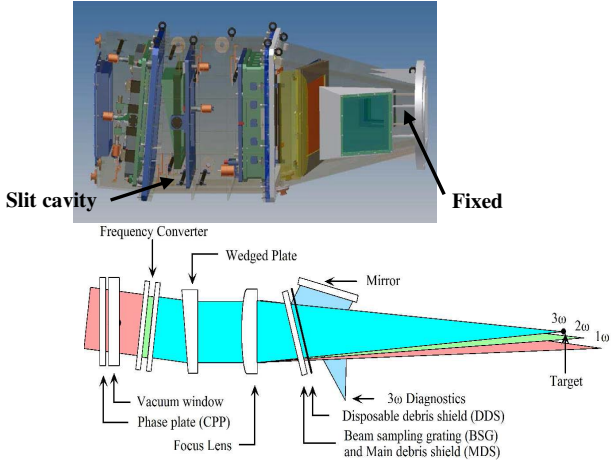


Figure 1. The prototype FOA is composed of fixed interfaces to the target chamber and five modules that house eight full-aperture optics. The clear aperture size is 310 mm × 310 mm.

doubler and a 10.5 mm-thick Type-II KDP tripler, optimized to achieve >70% peak power conversion efficiency to the third harmonic at a $1\omega_0$ driver irradiance of 3 GW cm^{-2} (Ref. [7]). The wedged plate, which is a prism with an edge angle of 11.22° , combines with the focus lens to realize a 2 mm separating distance of the fundamental and second harmonic away from the third harmonic target. The focus lens has a 45 mm-thick meniscus-aspheric surface for avoiding optical damage induced by ghost images of the fourth order for 1ω , 2ω , and 3ω . The BSG and MDS are made with 8 mm-thick fused silica possessing a 0.2% low-efficiency grating on the input surface for energy sampling. This setup provides transitions from the near-vacuum FOA environment to the hard-vacuum target chamber environment. The disposable debris shield is 2 mm-thick borosilicate glass. Here, the angle of the normal direction of the BSG and MDS to the DDS and the direction of the incident beam is 13.5° , which is used to deviate ghosts below the fourth order for $1\omega_0$, $2\omega_0$ and $3\omega_0$ from the direction of the incident beam. Inside the prototype FOA, the pressure is 10 Torr with 10 SLPM before the laser shot and 50 Torr with 40 SLPM after the laser shot using clean dry nitrogen to purge.

2. Clean-gas control

The optics in the prototype FOA are coated with a sol-gel anti-reflection film, but residuary (0.5%–1%) reflection also exists. Hence, these eight optics (including 16 surfaces) could form thousands of ghost images within the fourth-order reflection. If these ghost images are located on the optics, the optics would be directly damaged; if these ghost images move to other parts such as the mechanism, wire and silica gel (the paste around the optical elements, to guarantee the stability of the stress and deformation), the optics would

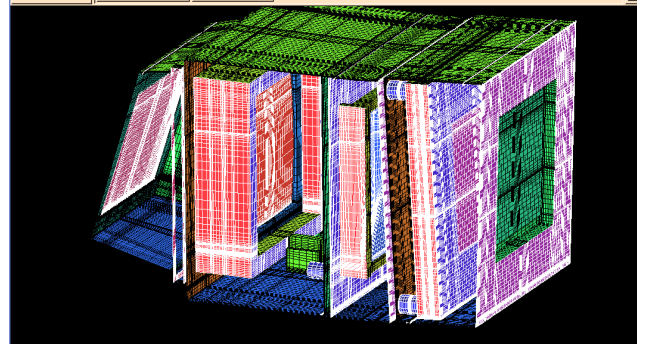


Figure 2. Numerical model of the FOA generated by ICEMCFD.

be indirectly damaged because of the contaminants. As shown in the last section, the BSG, MDS and DDS are tilted by 13.5° , and most of the ghost images are deflected from the main beam path to protect the optics. These ghost images lead to another problem, i.e., the presence of contaminants. To avoid contaminant sputtering to the optics, the following procedures are performed. First, the mechanism surfaces are treated with anodic oxidation. Second, clean gas is used to blow the optics surface to eliminate contaminants. In this section, a numerical simulation is carried out based on the FOA construction and a blowpipe arrangement, and the experimental results are presented.

2.1. Simulation analysis

The main physics process involved in the prototype FOA is the convection–diffusion process in the slit cavity (as indicated in Figure 1). The governing equations for this process can be written as

$$\frac{\partial \rho}{\partial t} + \frac{\partial}{\partial x_k} (\rho V_k) = 0, \quad (1)$$

$$\frac{DV_j}{Dt} = -\frac{1}{\rho_0} \frac{\partial (P - P_0)}{\partial x_j} + \nu \frac{\partial^2 V_j}{\partial x_k \partial x_k}, \quad (2)$$

$$\frac{Dc}{t} = \Gamma \frac{\partial^2 c}{\partial x_k \partial x_k}, \quad (3)$$

where V_i is the velocity vector ($i = 1, 2, 3$), t is time, ρ is the density of N_2 , ν is the kinematic viscosity of N_2 , c is the density of the aerosol in N_2 , p is the pressure of N_2 , p_0 is the reference pressure, and ρ_0 is the density in the reference point. Equation (1) is the continuity equation, Equation (2) is the momentum equation, and Equation (3) is the composition equation.

The standard k – ϵ model is used in the numerical simulation. This model is based on the hexahedron, and the gridding number is 2.9 million, as shown in Figure 2. The gridding is optimized with the Smoother tools of the Integrated Computer Engineering and Manufacturing code

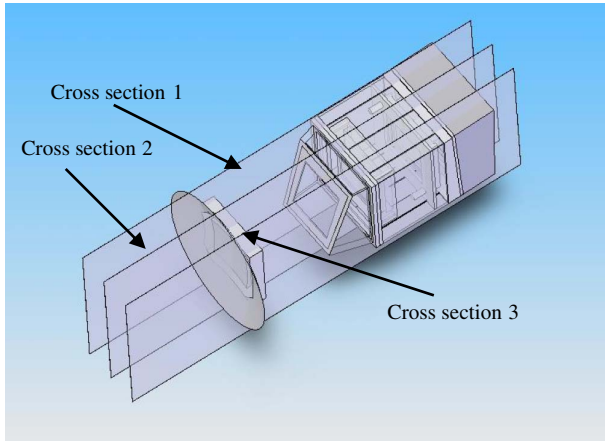


Figure 3. Schematic of the observed cross-section distributions in the prototype FOA.

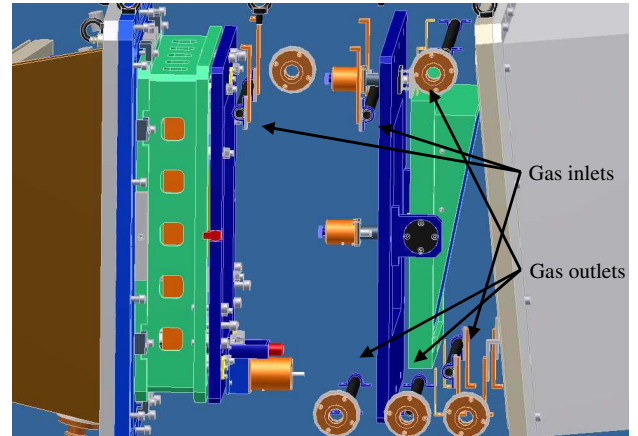


Figure 5. Distribution of the gas inlets and outlets in the FOA.



Figure 4. Density distribution of the contaminants in cross-section 2 as the flux ranges within 1–5 l s⁻¹ after 30 s.

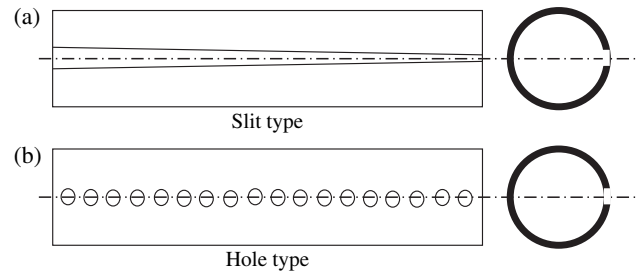


Figure 6. Two types of inlet and exhaust pipes.

for Computational Fluid Dynamics (ICEMCFD) based on the condition that the quality of the deformation rate above 0.8 is >90% and that all deformation rates are >0.3. The deformation rate is defined as the ratio of the diameter of the excircle to that of the incircle. A larger deformation rate corresponds to higher grinding quality.

Based on the above model, three cross-sections are analyzed, as shown in Figure 3. Flow situations of the flow field in the cavities of the prototype FOA at 100 Torr and constant pressure flux of 5 or 50 l s⁻¹ are simulated. Then, the ventilation efficiency on the optics surfaces and the density distribution of contaminants in the FOA are investigated for the above two fluxes. An entrance and an exit also exist in each cavity of the FOA.

The simulation results show that both 5 and 50 l s⁻¹ fluxes can maintain the relative density of the contaminants on the optics surfaces below 20% when the designed inlet pipe, exhaust pipe and spatial distribution are used. About 50 s after the laser launch, the contaminants decrease to 0.1% when 5 l s⁻¹ is used and 6% when 50 l s⁻¹ flux is used, as shown in Figure 4. Therefore, considering the contamination-elimination time, the flux is chosen within 1–5 l s⁻¹ and a 180 s period.

2.2. Gas-blowing scheme

In this section, the sizes, quantities and positions of the entrance and the exit as well as the gas-flow rate and hold time required for the contaminant elimination are given, based on numerical analysis of the gas-flow characteristics in the prototype FOA. Figure 5 shows the distributions of the inlet pipes and the corresponding flanges. The FOA includes nine entrances and five exits.

The N₂ used is 99.99% pure, and the H₂O content is less than 3 ppm. Gas is transported to the location where the aerosol needs to be blown by the inlet pipe. Figure 6 presents two types of inlet and exhaust pipes. To ensure uniform speed of the gas flow along the axial direction, the slit width is gradually increased from the point near the entrance to that near the exit for the slit-type pipe, as shown in Figure 6(a). For the small hole type (Figure 6(b)), the hole diameter is increased and the distance between the adjacent holes is decreased gradually from the point near the entrance to that near the exit.

The configurations of the exhaust pipes are similar to those of the inlet pipes. To ensure uniform speed of the exhaust flow along the axial direction, the slit width is gradually increased from the point near the exit to the far end for the slit-type pipe. For the small hole type, the hole diameter is increased and the distance between the adjacent holes

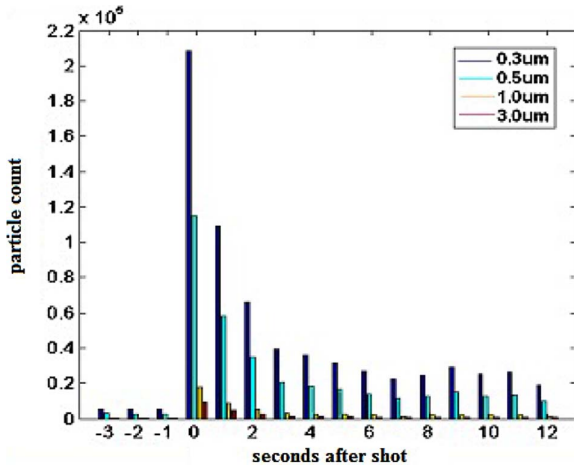


Figure 7. Graph showing the real-time contaminant quantity.

is gradually decreased from the point near the exit to the far end.

2.3. Experimental results

In the experiment, the flow controller is triggered at the same time as the laser fires. The flow flux is 40 SLPM. The particle

counter is used to detect contamination. Figure 7 shows that the contaminant quantity increases from 3000 particles before the laser fires to 140 000–210 000 particles after the firing. Thus, the particle density contrast is about 1:70. The optics surfaces is spotted after 33 shots. During the experiment, results obtained by the particle counter are taken from one of the exits. Hence, these results represent the relative density variation of the contaminants rather than the absolute quantity.

3. Optical damage

3.1. Damage morphology induced by the contaminants

Using an Msu25D high-resolution microscope, damage morphology is detected. Figure 8 shows the presence of surface ‘mooning’ damage and a surface spot located outside the clear aperture and induced by contaminants apart from the common damage morphologies, such as surface pin-point damage, block peeling, long scratching, and bulk filament^[7–9]. Here, surface mooning damage is serious in the center and changes the color of the film, induced by metal contaminants.

The components and morphologies of the contaminants are different; thus, the damage morphologies are also

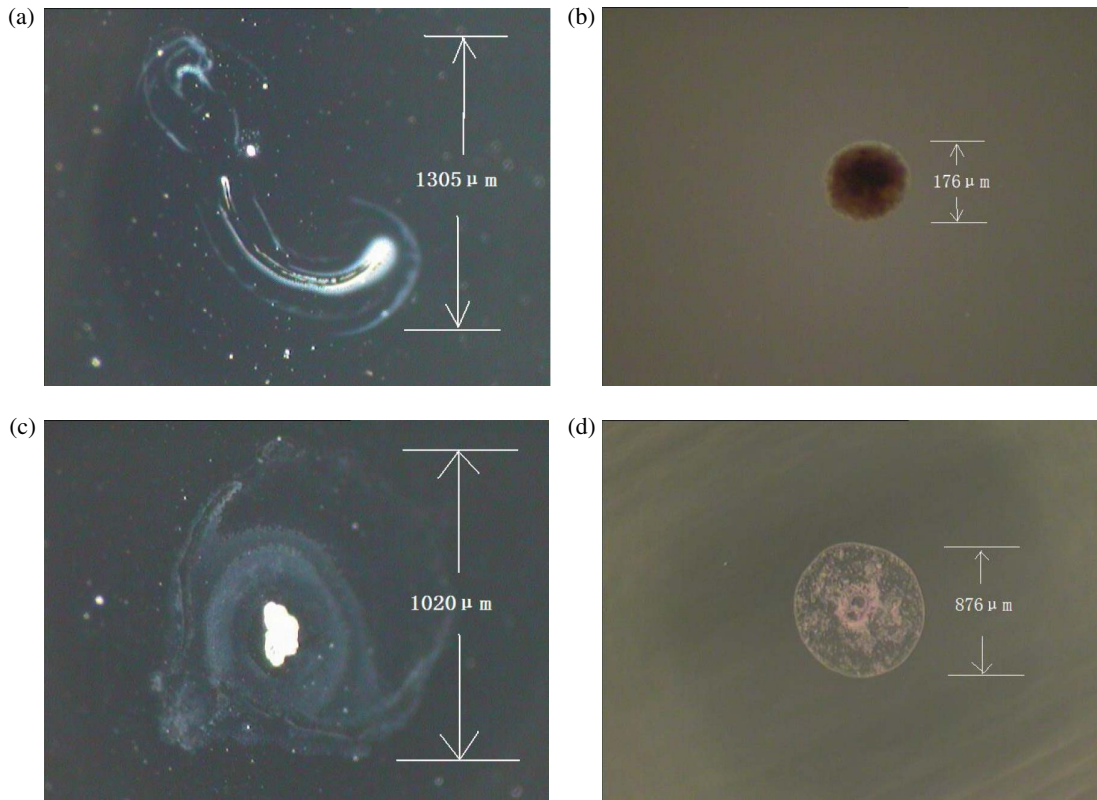


Figure 8. Surface damage morphologies induced by contaminants: (a) film damage located on the clear aperture brim, (b) surface spot outside the clear aperture, (c) clear aperture brim and (d) surface ‘mooning’ damage outside the clear aperture.

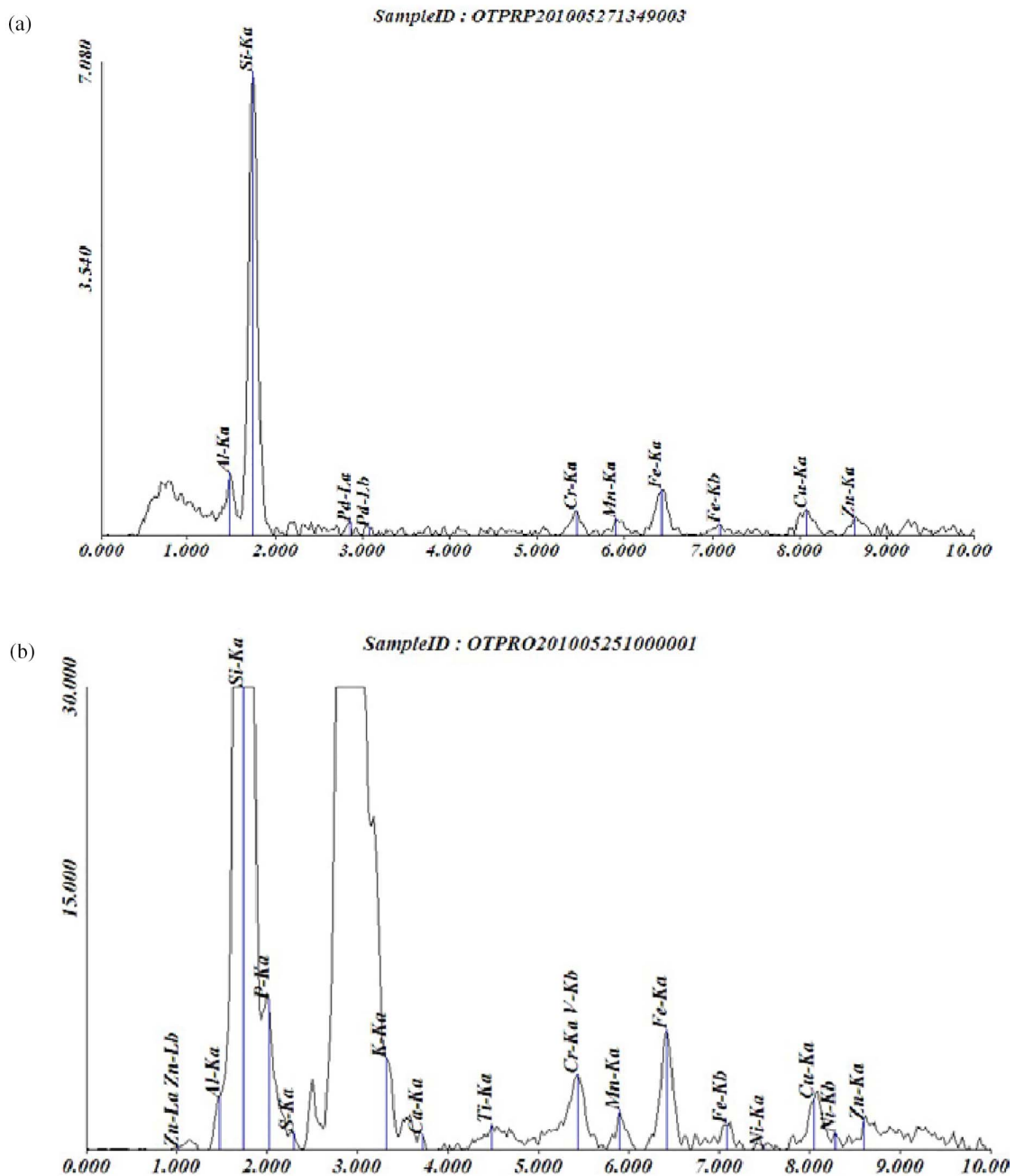


Figure 9. Results obtained by x-ray fluorescence spectrometry: (a) unused silica coated by sol-gel film (including Al, Si, Pd, Cr, Mn, Fe, Cu and Zn) and (b) used silica coated by sol-gel film (including Zn, Al, Si, P, S, K, Ca, Ti, Cr, Mn, Fe, Ni and Cu; because the Pb amount is negligible, it is not labeled).

different. The different figure subparts are explained as follows.

- (a) Figure 8(a) is induced by millimeter order fibers absorbing on the optics surfaces. After less than 0.1 J cm^{-2} order laser irradiation, the fiber is ablated and induces film damage. Suffering from multiple irradiations, the damage size increases and induces substrate damage. Given that the heat absorption coefficient of the fiber is low, this kind of damage cannot induce catastrophic bulk peeling.

- (b) Figure 8(b) is induced by wire and silica gel. Occurrences of this kind of morphology are numerous on the optics surfaces. If the wire and silica gel are irradiated by a laser, parts of them volatilize and are then absorbed on the optics surfaces. After several irradiations by stray light, they appear ablated but do not damage the sol-gel film.

- (c) Figure 8(c) is induced by millimeter order metal contaminants. The substrate is damaged, and the surface 'mooning' damage of the sol-gel film appears. This

kind of damage is due to the optics surface being affected by metal particle sputtering. After less than 0.1 J cm^{-2} order laser irradiation, the damage size increases and the sub-millimeter order damage points are uniformly distributed in the clear aperture because of the high absorption coefficient of the metal.

- (d) Figure 8(d) is induced by the same millimeter order metal contaminants. The substrate is seriously damaged in the center, and surface ‘mooning’ damage of the sol-gel film appears in the periphery. This phenomenon is also induced by the metal contaminants but occurs outside the clear aperture and is irradiated by the stray light.

3.2. Component analysis of the contamination

Parameters such as the components of the laser-induced damage point, the irradiated point without damage and the un-irradiated point, as well as the mechanical material, wire, silica gel, unused silica and chemical films, are analyzed by energy-dispersive x-ray fluorescence spectrometry. Figure 9 shows that the new components S, P, K, Ca, Mn, Al and Pd appear and that the contents of the Fe and Cu increase in the used optics compared with the unused optics. Al and Pd come from the sol-gel film; S, P and K are from the silica gel used to fix the optics; Ti and Cu come from the metal material sputtering of the prototype FOA. Molecular contaminants were not analyzed by Raman spectrometry because of the large optics size ($360 \text{ mm} \times 370 \text{ mm}$).

4. Conclusions

The uniform distribution of hundred-micron-order punctiform damage in the clear aperture and the uniform distri-

bution of ‘mooning’ damage or surface spots outside the clear aperture suggest that the contaminants induced by stray light because of the residual reflection from the mechanical metals, silica gel and wire are the main reasons for the damage increase. The gas flow used in the experiment eliminates certain contaminants, but ineffectively. Surface treatment of the metallic material is not completely effective for elimination of contaminants. Stray light absorbing traps are required in the prototype.

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